

## Surface deformation of nematic elastomers under striped illumination

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Nematic elastomers containing azobenzene chromophores are activated upon photoabsorption. We study the surface deformation of such elastomers under striped illumination. For an arbitrary orientation of the nematic axis, we obtain an analytical solution to the problem via a phenomenological continuum model. Numerical computations indicate that the profile of the deformed surface depends not only on the stripe width but also on the orientation of the nematic axis. The result may provide a mechanism to manipulate the surface topography of elastomers.

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### I. INTRODUCTION

Nematic elastomers can be made as large monodomains [1]. The most remarkable property of the material is that it exhibits large spontaneous contraction along the nematic axis when the degree of alignment order is changed. Typically, this can be achieved by heating through the nematic-isotropic transition temperature [2,3]. Another more novel route is by light irradiation, provided that azobenzene chromophores are incorporated into the elastomers. In the absence of illumination, the chromophores are in the rodlike *trans* state. Light irradiation gives rise to photoisomerization of the chromophores from the *trans* to the strongly kinked *cis* state, thereby lowering the nematic order [4–6]. Essentially, both methods can produce the same amount of spontaneous strain, and the related thermal and optical effects can be exactly mapped onto each other [4]. A similar optical response has been found in polydomain and amorphous elastomers as well.

The unique photoelastic behavior of the nematic elastomers is especially attractive for applications in light-driven mechanical actuations [7–10]. For example, when one side of such a film is illuminated uniformly, most of the incident photons are absorbed by the surface layer of a very small thickness. The degree of photoisomerization decays rapidly with the penetration depth, thus forming a gradient of photostrain across the thickness that results in the bending of the film. Obviously, the orientation of nematic axis can strongly affect the magnitude and anisotropy of photostrains. Experiments indicate that a film with nematic axis parallel to the surface bends towards the light source, while a film with nematic axis normal to the surface bends away from it [9]. More interesting is the case of polydomain nematic elastomer films: the bending in any direction can be evoked [7]. One can optimize a film actuator made of nematic elastomers by appropriately choosing the geometry and the direction of nematic axis [11].

When the elastomers are exposed to a nonuniform illumination pattern, however, the situation becomes different. A photostrain is induced in the irradiated part but not anywhere

else, leading to the formation of pits and bumps on the elastomer surface. Warner and Mahadevan [11] proposed a scaling analysis of pits and bumps induced by shining light in circular spots onto the surface of a monodomain nematic elastomer film with the nematic axis normal to the surface and suggested its use as writable structures in microfluidics, switchable reflector elements in projective displays, etc. The idea is reminiscent of the inscription of the surface relief gratings onto amorphous or liquid-crystalline polymers containing azobenzene chromophores [12–14]. Nevertheless, the microscopic scenario in the nematic elastomers is quite different, as an occasional cross-link between chains resists large-scale mass transport and elastic distortion becomes a predominant concern. Recently, Wei and He [15] performed a detailed numerical computation of the surface profile of the film analyzed by Warner and Mahadevan [11]. An interesting finding is that the photoinduced surface topography strongly depends on the radius of the light spot. The phenomenon can be attributed to elastic confinement from the less irradiated surrounding material. Consequently, in addition to illumination patterns, the distribution of elastic deformation is another influential factor for the surface profile of the elastomers.

Since the distribution of photostrain in a nematic elastomer depends on the direction of the nematic axis, the latter providing a mechanism of tailoring the field of elastic deformation. Motivated by this reason, this paper studies the effect of the orientation of the nematic axis on the photoinduced surface topography of the elastomers. For simplicity, we consider a monodomain nematic elastomer with flat surface under striped illumination of a single beam in the low pumping limit, where the orientation of the nematic axis can be arbitrary. In this circumstance, we are able to obtain an analytical steady-state solution to the surface deformation by using a phenomenological continuum model. Our analysis predicts a similar dependence of the photoinduced surface profile on the stripe width as in the case of circular light spots [15]. Moreover, we demonstrate that the orientation of the nematic axis lends itself to an adjustable parameter that can efficiently control the surface profile. The results may be used to manipulate the surface topography of azobenzene-containing nematic elastomers by nonuniform illumination.

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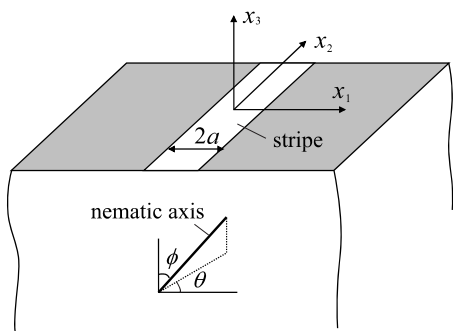


FIG. 1. Schematic illustration of the problem. A nematic elastomer is illuminated by a normally incident beam, leaving a stripe parallel to the  $x_2$  direction on the surface. The nematic axis of the elastomer is arbitrarily aligned, it makes an angle  $\phi$  with the  $x_3$  direction, and its projection on the  $x_1$ - $x_2$  plane makes an angle  $\theta$  with the  $x_1$  direction.

## II. FUNDAMENTAL FORMULATION

Monodomain nematic elastomers can be used as thin films glued onto rigid substrates, and any longitudinal deformations in the film lead to shear strains due to the restriction of the substrates [11]. When the film is sufficiently thick, photoinduced deformations in the surface region undergo a similar restriction by the less distorted underlying material [15]. Therefore, for this reason and for simplicity, we consider a semi-infinite monodomain nematic elastomer that occupies the half-space  $x_3 < 0$ , with the initially flat surface coinciding with the  $x_1$ - $x_2$  plane. As depicted in Fig. 1, the nematic axis of the elastomer can be along an arbitrary direction characterized by two angles  $\theta$  and  $\phi$ , where  $\theta$  stands for the angle between the projection of the nematic axis on the surface and the  $x_1$  direction, while  $\phi$  is the angle between the nematic axis and the  $x_3$  direction. Suppose that a light beam is incident normal to the elastomer, leaving a stripe of width  $2a$  on the surface. The two parallel boundaries of the stripe are  $x_1 = \pm a$ , respectively, and the intensity on the surface is expressed in the unified form as  $I(x_1, x_2) = IH(a - |x_1|)$ . Here  $I$  is a constant and  $H(x)$  refers to the Heaviside function that equals unity for  $x \geq 0$  and vanishes for  $x < 0$ . We will study the surface deformation of the elastomer.

Before going into details, it is helpful to recall some previous results concerning photoinduced strains in a free sample of a nematic elastomer under homogeneous illumination [3–6]. Denote the number density of the azobenzene chromophores in total by  $\phi_0$ . A homogeneous illumination of intensity  $I$  depletes the *trans* population at a rate  $-\eta I(\phi_0 - \phi_c)$ , where  $\eta$  is the molecular absorption coefficient and  $\phi_c$  the number density of the resulting *cis* isomers. The *cis* concentration increases, and then there is a back reaction to the *trans* state. The back reaction rate depends on the *cis* population and the lifetime  $\tau_{ct}$ , and is expressed by  $\phi_c / \tau_{ct}$ . In the stationary state, the forward and back reactions are balanced, giving  $\phi_c = \eta I \tau_{ct} \phi_0 / (1 + \eta I \tau_{ct})$ . In the low-illumination limit  $\eta I \tau_{ct} \ll 1$ , one has  $\phi_c = \eta I \tau_{ct} \phi_0$ . Such a small amount of bent *cis* isomers disrupts the nematic order and leads to a spontaneous contraction proportional to  $\phi_c$  along the nematic axis. Therefore, assuming incompressibility of the elastomer, the

photostrains parallel and normal to the director axis are both uniform and read  $\varepsilon_{\parallel}^* = -\alpha I$  and  $\varepsilon_{\perp}^* = \alpha I / 2$ , respectively, where  $\alpha = c \eta \tau_{ct} \phi_0$  and  $c$  is a phenomenological constant.

Clearly, the situation of the elastomer half-space under inhomogeneous illumination is much more complicated. The intensity  $I(x_1, x_2, x_3)$  not only varies on the elastomer surface but also decreases with the penetration depth according to the Lambert-Beer law  $I(x_1, x_2, x_3) = I(x_1, x_2) e^{x_3/d}$ , in which  $d$  is the characteristic attenuation length. Thus, at an arbitrary point, the nonzero components of stationary photostrain are  $\varepsilon_{\parallel}^* = -\alpha I(x_1, x_2) e^{x_3/d}$  and  $\varepsilon_{\perp}^* = \alpha I(x_1, x_2) e^{x_3/d} / 2$ . Making use of coordinate transformation, the components of the stationary photostrain  $\varepsilon_{ij}^*$  referring to the  $(x_1, x_2, x_3)$  system are obtained as

$$\varepsilon_{ij}^* = \lambda_{ij} I(x_1, x_2) e^{x_3/d}, \quad (1)$$

where Latin indices range from 1 to 3, and  $\lambda_{ij}$  are given by

$$\lambda_{11} = \frac{\alpha}{2} (1 - 3 \cos^2 \theta \sin^2 \phi),$$

$$\lambda_{22} = \frac{\alpha}{2} (1 - 3 \sin^2 \theta \sin^2 \phi),$$

$$\lambda_{33} = \frac{\alpha}{2} (1 - 3 \cos^2 \phi),$$

$$\lambda_{12} = \lambda_{21} = -\frac{3\alpha}{2} \sin \theta \cos \theta \sin^2 \phi,$$

$$\lambda_{13} = \lambda_{31} = -\frac{3\alpha}{2} \cos \theta \sin \phi \cos \phi,$$

$$\lambda_{23} = \lambda_{32} = -\frac{3\alpha}{2} \sin \theta \sin \phi \cos \phi. \quad (2)$$

The inhomogeneous photostrain is incompatible, resulting in the deformation of an irradiated element in the elastomer undergoing elastic confinement from the surrounding material. The total strain is the sum of the photostrain and the corresponding elastic strain.

Although some continuum theories have been developed for nematic elastomers [3,16,17], none of them incorporated the effect of photostrains. Only recently, Warner and Mahadevan [11] proposed a phenomenological model accounting for the photoinduced deformation of azobenzene-containing nematic elastomers. The model involves two assumptions: the deformation is small, and the nematic axis does not rotate. These are reasonable in the low-illumination limit, and the corresponding predictions can show an informative trace of real physics. Accordingly, the same assumptions will be utilized in this paper. To be general, we denote the components of displacement, strain, and stress in the elastomer by  $u_i$ ,  $\varepsilon_{ij}$ , and  $\sigma_{ij}$ , respectively. The total strain is calculated by  $\varepsilon_{ij} = (\partial u_i / \partial x_j + \partial u_j / \partial x_i) / 2$ , and the elastic strain is  $\varepsilon_{ij} - \varepsilon_{ij}^*$ . By assuming elastic isotropy and incompressibility, the constitutive law of the elastomer is written as  $\sigma_{ij} =$

$-p\delta_{ij}+2\mu(\varepsilon_{ij}-\varepsilon_{ij}^*)$ , where  $p=-\sigma_{kk}/3$  is the hydrostatic pressure,  $\mu$  the shear modulus, and  $\delta_{ij}$  the Kronecker delta which equals unity if  $i=j$  and vanishes if  $i\neq j$ . Here and in the following, Einstein's summation convention is applied for repeated indices. In the absence of body force, the stress components satisfy the equilibrium equation  $\partial\sigma_{ij}/\partial x_j=0$ . Upon the use of the constitutive law and the incompressibility condition  $\partial u_k/\partial x_k=0$ , we derive from the equilibrium equation that

$$\mu\left(\frac{\partial^2 u_i}{\partial x_1^2} + \frac{\partial^2 u_i}{\partial x_2^2} + \frac{\partial^2 u_i}{\partial x_3^2}\right) - \frac{\partial p}{\partial x_i} = 2\mu \frac{\partial \varepsilon_{ij}^*}{\partial x_j}. \quad (3)$$

Together with  $\partial u_k/\partial x_k=0$ , the above equations completely describe the steady-state deformation of the elastomer. The associated boundary conditions on the traction-free surface  $x_3=0$  are  $\sigma_{i3}=0$ .

Since the elastomer is illuminated with the stripe parallel to the  $x_2$  direction, its photoelastic response is independent of  $x_2$ —i.e.,  $u_i=u_i(x_1, x_3)$  and  $p=p(x_1, x_3)$ . As a consequence, Eq. (3) is reduced to

$$\begin{aligned} \mu\left(\frac{\partial^2 u_1}{\partial x_1^2} + \frac{\partial^2 u_1}{\partial x_3^2}\right) - \frac{\partial p}{\partial x_1} &= 2\mu\left(\frac{\partial \varepsilon_{11}^*}{\partial x_1} + \frac{\partial \varepsilon_{13}^*}{\partial x_3}\right), \\ \frac{\partial^2 u_2}{\partial x_1^2} + \frac{\partial^2 u_2}{\partial x_3^2} &= 2\left(\frac{\partial \varepsilon_{12}^*}{\partial x_1} + \frac{\partial \varepsilon_{23}^*}{\partial x_3}\right), \\ \mu\left(\frac{\partial^2 u_3}{\partial x_1^2} + \frac{\partial^2 u_3}{\partial x_3^2}\right) - \frac{\partial p}{\partial x_3} &= 2\mu\left(\frac{\partial \varepsilon_{13}^*}{\partial x_1} + \frac{\partial \varepsilon_{33}^*}{\partial x_3}\right), \end{aligned} \quad (4)$$

and the incompressibility condition becomes

$$\frac{\partial u_1}{\partial x_1} + \frac{\partial u_3}{\partial x_3} = 0. \quad (5)$$

To solve these coupled equations, the first and third equations in Eqs. (4) are differentiated with respect to  $x_1$  and  $x_3$ , respectively. This leads to

$$\begin{aligned} \mu\left(\frac{\partial^3 u_1}{\partial x_1^3} + \frac{\partial^3 u_1}{\partial x_1 \partial x_3^2}\right) - \frac{\partial^2 p}{\partial x_1^2} &= 2\mu\left(\frac{\partial^2 \varepsilon_{11}^*}{\partial x_1^2} + \frac{\partial^2 \varepsilon_{13}^*}{\partial x_1 \partial x_3}\right), \\ \mu\left(\frac{\partial^3 u_3}{\partial x_1^2 \partial x_3} + \frac{\partial^3 u_3}{\partial x_3^3}\right) - \frac{\partial^2 p}{\partial x_3^2} &= 2\mu\left(\frac{\partial^2 \varepsilon_{13}^*}{\partial x_1 \partial x_3} + \frac{\partial^2 \varepsilon_{33}^*}{\partial x_3^2}\right). \end{aligned} \quad (6)$$

In view of Eq. (5), we can replace  $\partial u_3/\partial x_3$  in the second one in Eqs. (6) by  $-\partial u_1/\partial x_1$ . A comparison of the resulting equation with the first one in Eqs. (6) immediately gives

$$\frac{\partial^2 p}{\partial x_1^2} + \frac{\partial^2 p}{\partial x_3^2} = -2\mu\left(\frac{\partial^2 \varepsilon_{11}^*}{\partial x_1^2} + 2\frac{\partial^2 \varepsilon_{13}^*}{\partial x_1 \partial x_3} + \frac{\partial^2 \varepsilon_{33}^*}{\partial x_3^2}\right). \quad (7)$$

Thus, given that  $p$  is obtained from the above, the displacements  $u_1$ ,  $u_2$ , and  $u_3$  can be solved from the three equations (4) separately. In the meantime, the condition (5) provides some relations between the undetermined constants in the solutions, as will be seen in the subsequent section.

### III. ANALYTICAL SOLUTION

As the deformation of the elastomer decays far away from the illuminated region, we can represent all the components of displacement, hydrostatic pressure, and photostrain by the Fourier integrals

$$\begin{aligned} u_i(x_1, x_3) &= \int_{-\infty}^{\infty} \bar{u}_i(\xi, x_3) e^{i\xi x_1} d\xi, \\ p(x_1, x_3) &= \int_{-\infty}^{\infty} \bar{p}(\xi, x_3) e^{i\xi x_1} d\xi, \\ \varepsilon_{ij}^*(x_1, x_3) &= \int_{-\infty}^{\infty} \bar{\varepsilon}_{ij}^*(\xi, x_3) e^{i\xi x_1} d\xi, \end{aligned} \quad (8)$$

in which  $i=\sqrt{-1}$  and an overbar refers to the corresponding Fourier transform. For example,  $\bar{\varepsilon}_{ij}^*$  is defined by

$$\bar{\varepsilon}_{ij}^*(\xi, x_3) = \frac{1}{2\pi} \int_{-\infty}^{\infty} \varepsilon_{ij}^*(x_1, x_3) e^{-i\xi x_1} dx_1, \quad (9)$$

which, in combination with Eq. (1), gives  $\bar{\varepsilon}_{ij}^*(\xi, x_3) = \lambda_{ij} l e^{x_3/d} \sin(a\xi) / \pi\xi$ . Upon the substitution of Eqs. (8) into Eqs. (4), (5), and (7), we arrive at

$$\begin{aligned} \frac{\partial^2 \bar{p}}{\partial x_3^2} - \xi^2 \bar{p} &= 2\mu\left(\xi^2 \bar{\varepsilon}_{11}^* - 2i\xi \frac{\partial \bar{\varepsilon}_{13}^*}{\partial x_3} - \frac{\partial^2 \bar{\varepsilon}_{13}^*}{\partial x_3^2}\right), \\ \mu\left(\frac{\partial^2 \bar{u}_1}{\partial x_3^2} - \xi^2 \bar{u}_1\right) - i\xi \bar{p} &= 2\mu\left(i\xi \bar{\varepsilon}_{11}^* + \frac{\partial \bar{\varepsilon}_{13}^*}{\partial x_3}\right), \\ \frac{\partial^2 \bar{u}_2}{\partial x_3^2} - \xi^2 \bar{u}_2 &= 2\left(i\xi \bar{\varepsilon}_{12}^* + \frac{\partial \bar{\varepsilon}_{23}^*}{\partial x_3}\right), \\ \mu\left(\frac{\partial^2 \bar{u}_3}{\partial x_3^2} - \xi^2 \bar{u}_3\right) - \frac{\partial \bar{p}}{\partial x_3} &= 2\mu\left(i\xi \bar{\varepsilon}_{13}^* + \frac{\partial \bar{\varepsilon}_{33}^*}{\partial x_3}\right), \\ \frac{\partial \bar{u}_3}{\partial x_3} + i\xi \bar{u}_1 &= 0. \end{aligned} \quad (10)$$

The solutions to the above ordinary differential equations can be obtained as

$$\begin{aligned} \bar{u}_1 &= c_1 e^{|\xi|x_3} - ic_4 \frac{1-2|\xi|x_3}{4\mu\xi} e^{|\xi|x_3} \\ &\quad + \frac{2Id[\lambda_{13}(1+d^2\xi^2) + i(\lambda_{11}-\lambda_{33})d\xi]}{\pi\xi(1-d^2\xi^2)^2} e^{x_3/d} \sin(a\xi), \\ \bar{u}_2 &= c_2 e^{|\xi|x_3} + \frac{2Id(\lambda_{23} + i\lambda_{12}d\xi)}{\pi\xi(1-d^2\xi^2)} e^{x_3/d} \sin(a\xi), \\ \bar{u}_3 &= c_3 e^{|\xi|x_3} - c_4 \frac{1-2|\xi|x_3}{4\mu|\xi|} e^{|\xi|x_3} \\ &\quad - \frac{2Id^2[i\lambda_{13}(1+d^2\xi^2) - (\lambda_{11}-\lambda_{33})d\xi]}{\pi\xi(1-d^2\xi^2)^2} e^{x_3/d} \sin(a\xi), \end{aligned}$$

$$\bar{p} = c_4 e^{|\xi|x_3} - \frac{2\mu I(\lambda_{33} + 2i\lambda_{13}d\xi - \lambda_{11}d^2\xi^2)}{\pi\xi(1-d^2\xi^2)} e^{x_3/d} \sin(a\xi), \quad (11)$$

where  $c_4 = -2\mu(i\xi c_1 + |\xi|c_3)$  and  $c_1$ ,  $c_2$ , and  $c_3$  are yet unknown constants. Note that the relation between  $c_1$ ,  $c_3$ , and  $c_4$  has been derived by inserting Eqs. (11) into Eq. (5). To determine the unknown constants, we apply Fourier integral transforms to the surface boundary conditions and invoke the constitutive law. This results in  $\partial\bar{u}_1/\partial x_3 + i\xi\bar{u}_3 - 2\bar{\epsilon}_{13}^* = 0$ ,  $\partial\bar{u}_2/\partial x_3 - 2\bar{\epsilon}_{23}^* = 0$ , and  $2\mu(\partial\bar{u}_3/\partial x_3 - \bar{\epsilon}_{33}^*) - \bar{p} = 0$  at  $x_3 = 0$ . Substitution of Eqs. (11) into these relations yields

$$c_1 = -\frac{dI(3-d|\xi|)[i(\lambda_{11}-\lambda_{33})(1+d^2\xi^2) + 4\lambda_{13}d\xi]\sin(a\xi)}{2\pi|\xi|(1-d^2\xi^2)^2},$$

$$c_2 = -\frac{2dI(i\lambda_{12} + \lambda_{23}d\xi)\sin(a\xi)}{\pi|\xi|(1-d^2\xi^2)},$$

$$c_3 = -\frac{dI(1+d|\xi|)[(\lambda_{11}-\lambda_{33})(1+d^2\xi^2) - 4i\lambda_{13}d\xi]\sin(a\xi)}{2\pi\xi(1-d^2\xi^2)^2}. \quad (12)$$

With the results in Eqs. (11) and (12), the displacement components of the elastomer are determined in integral forms as in Eqs. (8). In particular the surface displacement field is expressed by

$$u_1(x_1, 0) = \frac{dI}{\pi} \int_{-\infty}^{\infty} \frac{[2\lambda_{13} - i(\lambda_{11} - \lambda_{33})\text{sgn}(t)]\sin(rt)}{t(1+|t|)^2} e^{i\rho t} dt,$$

$$u_2(x_1, 0) = \frac{2dI}{\pi} \int_{-\infty}^{\infty} \frac{[\lambda_{23} - i\lambda_{12}\text{sgn}(t)]\sin(rt)}{t(1+|t|)} e^{i\rho t} dt,$$

$$u_3(x_1, 0) = -\frac{dI}{\pi} \int_{-\infty}^{\infty} \frac{[(\lambda_{11} - \lambda_{33})\text{sgn}(t) + 2i\lambda_{13}]\sin(rt)}{(1+|t|)^2} e^{i\rho t} dt, \quad (13)$$

in which  $t$ ,  $r$ , and  $\rho$  are dimensionless parameters defined by

$$t = d\xi, \quad r = \frac{a}{d}, \quad \rho = \frac{x_1}{d}. \quad (14)$$

Obviously, the expression of  $u_1(x_1, 0)$  in Eqs. (13) can be rewritten as

$$u_1(x_1, 0) = \frac{dI}{\pi} \left\{ \int_{-\infty}^0 \frac{[2\lambda_{13} + i(\lambda_{11} - \lambda_{33})]\sin(rt)e^{i\rho t}}{t(1-t)^2} dt + \int_0^{\infty} \frac{[2\lambda_{13} - i(\lambda_{11} - \lambda_{33})]\sin(rt)e^{i\rho t}}{t(1+t)^2} dt \right\}. \quad (15)$$

By taking a transformation  $t \rightarrow -t$  for the first integral and then performing a simple algebraic manipulation, it is obtained that

$$u_1(x_1, 0) = \frac{2dI}{\pi} \{ (\lambda_{11} - \lambda_{33})[I_1(\rho) - I_3(\rho)] + 2\lambda_{13}[I_2(\rho) - I_4(\rho)] \}. \quad (16)$$

Applying similar procedures to the expressions of  $u_2(x_1, 0)$  and  $u_3(x_1, 0)$  in Eqs. (13) leads to

$$u_2(x_1, 0) = \frac{4dI}{\pi} [\lambda_{12}I_1(\rho) + \lambda_{23}I_2(\rho)],$$

$$u_3(x_1, 0) = \frac{2dI}{\pi} [2\lambda_{13}I_3(\rho) - (\lambda_{11} - \lambda_{33})I_4(\rho)]. \quad (17)$$

In Eqs. (16) and (17), the functions  $I_1(\rho)$ ,  $I_2(\rho)$ ,  $I_3(\rho)$ , and  $I_4(\rho)$  are defined by

$$I_1(\rho) = \int_0^{\infty} \frac{\sin(\rho t)\sin(rt)}{t(1+t)} dt,$$

$$I_2(\rho) = \int_0^{\infty} \frac{\cos(\rho t)\sin(rt)}{t(1+t)} dt,$$

$$I_3(\rho) = \int_0^{\infty} \frac{\sin(\rho t)\sin(rt)}{(1+t)^2} dt,$$

$$I_4(\rho) = \int_0^{\infty} \frac{\cos(\rho t)\sin(rt)}{(1+t)^2} dt. \quad (18)$$

To evaluate these integrals, two cases have to be distinguished—i.e.,  $\rho \neq \pm r$  and  $\rho = \pm r$ . For  $\rho \neq \pm r$ , we can infer from Eqs. (18) that

$$I_1(\rho) = \int_0^{\infty} \frac{\sin(\rho t)\sin(rt)}{t} dt - \frac{1}{2} \int_0^{\infty} \frac{\cos(\rho-r)t}{1+t} dt + \frac{1}{2} \int_0^{\infty} \frac{\cos(\rho+r)t}{1+t} dt,$$

$$I_2(\rho) = \frac{1}{2} \int_0^{\infty} \frac{\sin(\rho+r)t}{t(1+t)} dt - \frac{1}{2} \int_0^{\infty} \frac{\sin(\rho-r)t}{t(1+t)} dt,$$

$$I_3(\rho) = \frac{1}{2} \int_0^{\infty} \frac{\cos(\rho-r)t}{(1+t)^2} dt - \frac{1}{2} \int_0^{\infty} \frac{\cos(\rho+r)t}{(1+t)^2} dt,$$

$$I_4(\rho) = \frac{1}{2} \int_0^{\infty} \frac{\sin(\rho+r)t}{(1+t)^2} dt - \frac{1}{2} \int_0^{\infty} \frac{\sin(\rho-r)t}{(1+t)^2} dt. \quad (19)$$

All the integrals in the above equation are convergent and can be represented in terms of some special functions [18]. The results are

$$I_1(\rho) = \frac{1}{2} \ln \left| \frac{\rho+r}{\rho-r} \right| + \frac{1}{4\sqrt{\pi}} \left[ G_{1,3}^{3,1} \left( \frac{|\rho+r|}{2}, \frac{1}{2} \middle| \begin{matrix} 0 \\ 0,0,1/2 \end{matrix} \right) - G_{1,3}^{3,1} \left( \frac{|\rho-r|}{2}, \frac{1}{2} \middle| \begin{matrix} 0 \\ 0,0,1/2 \end{matrix} \right) \right],$$

$$\begin{aligned}
I_2(\rho) &= \frac{\pi}{4} \{ [1 - \cos(\rho + r)] \operatorname{sgn}(\rho + r) - [1 - \cos(\rho - r)] \operatorname{sgn}(\rho - r) \} \\
&\quad - \frac{1}{2} [\operatorname{Ci}(|\rho + r|) \sin(\rho + r) - \operatorname{Ci}(|\rho - r|) \sin(\rho - r)] \\
&\quad + \frac{1}{2} [\operatorname{Si}(\rho + r) \cos(\rho + r) - \operatorname{Si}(\rho - r) \cos(\rho - r)], \\
I_3(\rho) &= \frac{1}{2\sqrt{\pi}} \left[ G_{1,3}^{3,1} \left( \frac{|\rho - r|}{2}, \frac{1}{2} \middle| \begin{matrix} 0 \\ 0, 1/2, 1 \end{matrix} \right) \right. \\
&\quad \left. - G_{1,3}^{3,1} \left( \frac{|\rho + r|}{2}, \frac{1}{2} \middle| \begin{matrix} 0 \\ 0, 1/2, 1 \end{matrix} \right) \right], \\
I_4(\rho) &= \frac{1}{2\sqrt{\pi}} \left[ G_{1,3}^{3,1} \left( \frac{|\rho + r|}{2}, \frac{1}{2} \middle| \begin{matrix} 1/2 \\ 1/2, 1/2, 1 \end{matrix} \right) \operatorname{sgn}(\rho + r) \right. \\
&\quad \left. - G_{1,3}^{3,1} \left( \frac{|\rho - r|}{2}, \frac{1}{2} \middle| \begin{matrix} 1/2 \\ 1/2, 1/2, 1 \end{matrix} \right) \operatorname{sgn}(\rho - r) \right]. \quad (20)
\end{aligned}$$

Here  $\operatorname{sgn}(x)$  is the sign function,  $\operatorname{Si}(x)$  and  $\operatorname{Ci}(x)$  are, respectively, the sine and cosine integral functions defined by

$$\operatorname{Si}(x) = \int_0^x \frac{\sin t}{t} dt, \quad \operatorname{Ci}(x) = - \int_x^\infty \frac{\cos t}{t} dt, \quad (21)$$

and  $G_{p,q}^{m,n}(x, r | a_1, \dots, a_p; b_1, \dots, b_q)$  is the Meijer  $G$  function [19] defined by

$$\begin{aligned}
G_{p,q}^{m,n}(x, r | a_1, \dots, a_p; b_1, \dots, b_q) &= \frac{1}{2\pi i} \\
&\times \int_{\gamma_1} \frac{\prod_{j=1}^m \Gamma(b_j + s) \prod_{j=1}^n \Gamma(1 - a_j - s)}{\prod_{j=n+1}^p \Gamma(a_j + s) \prod_{j=m+1}^q \Gamma(1 - b_j - s)} x^{-s/r} ds, \quad (22)
\end{aligned}$$

where  $i = \sqrt{-1}$ ,  $\Gamma(z)$  is the gamma function, and the contour  $\gamma_1$  is set up between the poles of  $\Gamma(1 - a_j - s)$  and the poles of  $\Gamma(b_j + s)$ .

For  $\rho = \pm r$ , however, the integrals in the expression of  $I_1(\rho)$  given by Eqs. (19) do not converge. To estimate  $I_1(\rho)$ , we can use its original definition in Eqs. (18) directly. The result is known [18] and reads

$$\begin{aligned}
I_1(\rho) &= \frac{1}{2} \left\{ \gamma + \ln 2r + \left[ \frac{\pi}{2} - \operatorname{Si}(2r) \right] \sin 2r \right. \\
&\quad \left. + \operatorname{Ci}(2r) \cos 2r \right\} \operatorname{sgn}(\rho). \quad (23)
\end{aligned}$$

In contrast, there are no such problems of convergency for  $I_2(\rho)$ ,  $I_3(\rho)$ , and  $I_4(\rho)$  in Eqs. (19). But due to  $\rho = \pm r$ , the corresponding expressions are simplified to

$$I_2(\rho) = \frac{\pi}{2} \sin^2 r + \frac{1}{2} [\operatorname{Si}(2r) \cos 2r - \operatorname{Ci}(2r) \sin(2r)],$$

$$I_3(\rho) = \frac{1}{2} \left[ 1 - \frac{1}{\sqrt{\pi}} G_{1,3}^{3,1}(r^2 | \begin{matrix} 0 \\ 0, 1/2, 1 \end{matrix}) \right] \operatorname{sgn}(\rho),$$

$$I_4(\rho) = \frac{1}{2\sqrt{\pi}} G_{1,3}^{3,1}(r^2 | \begin{matrix} 1/2 \\ 1/2, 1/2, 1 \end{matrix}). \quad (24)$$

#### IV. RESULTS AND DISCUSSIONS

The solution obtained in the preceding section enables us to analyze in detail the influences of such factors as stripe width and nematic axis direction on the photoinduced surface deformation of the elastomer. In the following, we will discuss first two special cases of  $\phi = \pi/2$  and  $\phi = 0$  and then the more general case of  $0 < \phi < \pi/2$ . For convenience, the surface displacement components are normalized as

$$U_1 = \frac{\pi}{\alpha d l} u_1(x_1, 0), \quad U_2 = \frac{\pi}{\alpha d l} u_2(x_1, 0), \quad U_3 = \frac{\pi}{\alpha d l} u_3(x_1, 0). \quad (25)$$

##### A. Case of $\phi = \pi/2$

When the nematic axis of the elastomer is aligned parallel to the surface, making an arbitrary angle  $\theta$  with the  $x_1$  direction, we have  $\phi = \pi/2$ . Then the nonzero components of  $\lambda_{ij}$  are  $\lambda_{11} = \alpha(1 - 3 \cos^2 \theta)/2$ ,  $\lambda_{22} = \alpha(1 - 3 \sin^2 \theta)/2$ ,  $\lambda_{33} = \alpha/2$ , and  $\lambda_{12} = -3\alpha \sin \theta \cos \theta/2$ , and the normalized surface displacement components become

$$\begin{aligned}
U_1 &= -3[I_1(\rho) - I_3(\rho)] \cos^2 \theta, \\
U_2 &= -3I_1(\rho) \sin 2\theta, \\
U_3 &= 3I_4(\rho) \cos^2 \theta. \quad (26)
\end{aligned}$$

Clearly, they depend on the angle  $\theta$ . At a given position  $\rho$  on the surface, the magnitudes of both  $U_1$  and  $U_3$  attain the

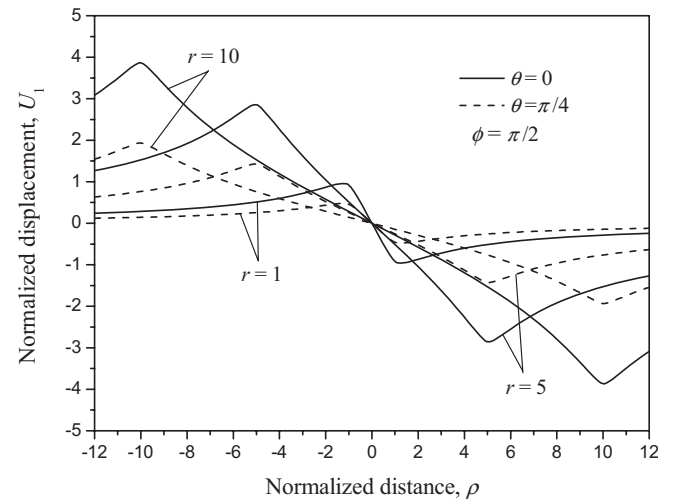


FIG. 2. Distributions of the normalized displacement  $U_1$  at different values of normalized stripe width  $r$ , where the nematic axis may have two orientations:  $\phi = \pi/2$  and  $\theta = 0$  or  $\phi = \pi/2$  and  $\theta = \pi/4$ .



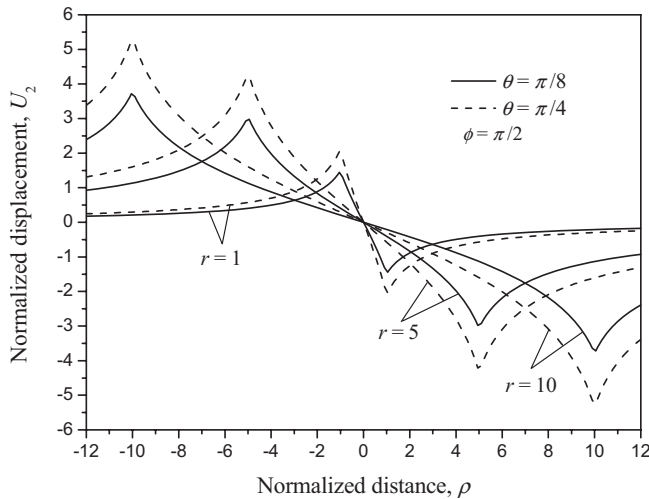


FIG. 3. Distributions of the normalized displacement  $U_2$  at different values of normalized stripe width  $r$ , where the nematic axis may have two orientations:  $\phi = \pi/2$  and  $\theta = \pi/8$  or  $\phi = \pi/2$  and  $\theta = \pi/4$ .

maximum when  $\theta = 0$  or  $\pi$ , while that of  $U_2$  takes the maximum when  $\theta = \pm \pi/4$ . If  $\theta = \pm \pi/2$ , all the displacement components vanish, because the photoinduced contraction of the elastomer in the  $x_2$  direction is fully constrained.

Figures 2 and 3 illustrate variations of  $U_1$  and  $U_2$ , respectively, in and around the illuminated regions with  $r = 1, 5$ , and 10 for some typical values of  $\theta$ . As expected, the displacement components exhibit antisymmetric distributions about the  $x_2$ - $x_3$  plane and depend not only on the angle  $\theta$  but also on the normalized stripe width  $r$ . For fixed  $\theta$  and  $r$ , the magnitudes of  $U_1$  and  $U_2$  increase with the dimensionless distance  $\rho$  increasing from the stripe center, attain the maximum at the two boundaries  $\rho = \pm r$ , and then experience a sharp transition to decrease. Varying  $\theta$  and  $r$  leads to changes in the magnitudes of  $U_1$  and  $U_2$ , but does not alter the fundamental feature of the displacement distributions. At a

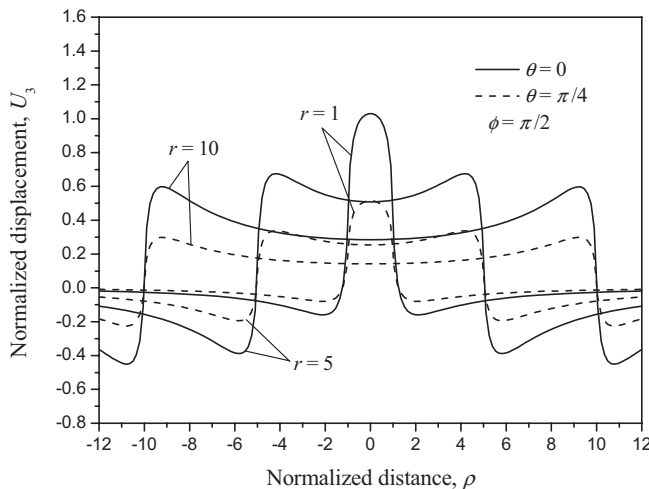
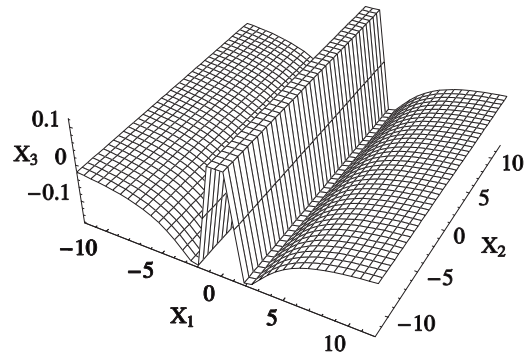
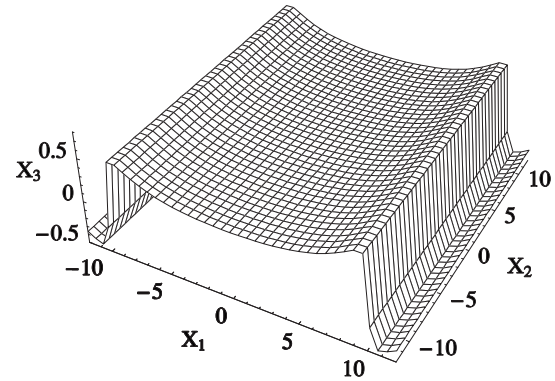


FIG. 4. Distributions of the normalized displacement  $U_3$  at different values of normalized stripe width  $r$ , where the nematic axis may have two orientations:  $\phi = \pi/2$  and  $\theta = 0$  or  $\phi = \pi/2$  and  $\theta = \pi/4$ .



(a)  $r = 1$



(b)  $r = 10$

FIG. 5. Surface topographies for two normalized stripe widths: (a)  $r = 1$  and (b)  $r = 10$ , where the orientation of the nematic axis is given by  $\phi = \pi/2$  and  $\theta = 0$ . The scales in the three directions are normalized by  $X_1 = x_1/d$ ,  $X_2 = x_2/d$ , and  $X_3 = \pi x_3/adl$ , respectively.

given angle  $\theta$ , the maximal displacements, appearing at  $\rho = \pm r$ , are considerably dependent on the normalized stripe width  $r$ . Depicted in Fig. 4 are the variations of  $U_3$  for  $r = 1, 5$ , and 10. All the results are symmetric about the  $x_2$ - $x_3$  plane. In contrast to the cases of  $U_1$  and  $U_2$ , the distribution of  $U_3$  changes qualitatively for different values of the stripe width  $r$ . For example, for  $r = 1$ ,  $U_3$  is maximal at the center ( $\rho = 0$ ) of the stripe, while for  $r = 5$  and 10, it attains the maximum at the positions closely near the stripe boundaries ( $\rho = \pm r$ ).

The surface topography of the elastomer after deformation is described by the position vector  $\mathbf{r} = [x_i + u_i(x_1, 0)]\mathbf{e}_i$ , where  $\mathbf{e}_i$  stands for the base vector of  $x_i$ . In the low-illumination limit considered here, due to  $\alpha l / \pi \ll 1$ , it can be verified that the position vector is nearly the same as  $\mathbf{r} = x_1\mathbf{e}_1 + x_2\mathbf{e}_2 + u_3(x_1, 0)\mathbf{e}_3$ . Thus, according to Eqs. (25), we can plot normalized three-dimensional profiles of the deformed surface under different conditions. Shown in Figs. 5(a) and 5(b) are two typical results for  $r = 1$  and 10, respectively, where  $\theta = 0$  is taken. For  $r = 1$ , a single ridge forms on the surface, while for  $r = 10$ , an M-shaped profile of the surface appears. This transition of surface topography can be explained analogously by elastic confinement as for the case of shining a beam in circular spots onto an elastomer with its nematic axis normal to the surface [15]. In fact, when the

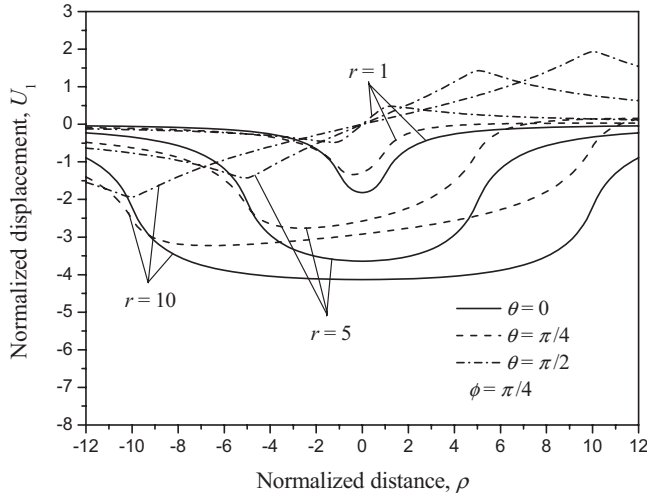


FIG. 6. Distributions of the normalized displacement  $U_1$  at different values of normalized stripe width  $r$ , where the nematic axis may have three orientations:  $\phi=\pi/4$  and  $\theta=0$ ,  $\phi=\pi/4$  and  $\theta=\pi/4$ , or  $\phi=\pi/4$  and  $\theta=\pi/2$ .

stripe width is very small, the contraction of the irradiated elastomer along the nematic axis bears resistance, mainly from the unexposed material near the stripe boundaries. As a consequence of the incompressibility, the illuminated elastomer protrudes while the unexposed material near the stripe boundaries caves in, just as the case in Fig. 5(a). When the stripe width is very large, however, the contraction undergoes an additional resistance from the underlying less deformed material. Accordingly, the actual contraction is significantly smaller in the central part than near the stripe boundaries. Therefore, the illuminated part of the elastomer protrudes more in the boundary region than at the center, forming a centrally concave surface topography shown in Fig. 5(b). This interpretation is consistent with the distribution of  $U_1$  in Fig. 2. We can see that the strain component  $\varepsilon_{11}$  is compressive and tensile in and out of the illuminated part,

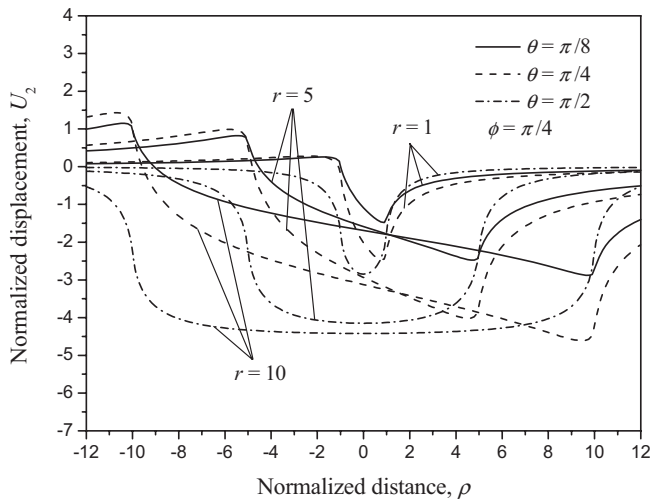


FIG. 7. Distributions of the normalized displacement  $U_2$  at different values of normalized stripe width  $r$ , where the nematic axis may have three orientations:  $\phi=\pi/4$  and  $\theta=\pi/8$ ,  $\phi=\pi/4$  and  $\theta=\pi/4$ , or  $\phi=\pi/4$  and  $\theta=\pi/2$ .

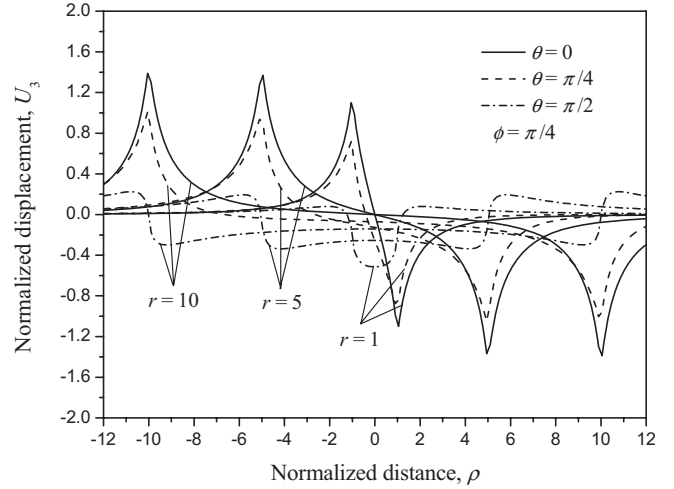


FIG. 8. Distributions of the normalized displacement  $U_3$  at different values of normalized stripe width  $r$ , where the nematic axis may have three orientations:  $\phi=\pi/4$  and  $\theta=0$ ,  $\phi=\pi/4$  and  $\theta=\pi/4$ , or  $\phi=\pi/4$  and  $\theta=\pi/2$ .

respectively. For a small value of  $r$ , the compressive strain in the illuminated material is nearly constant; for a large value of  $r$ , the strain is smaller at the center than in the region near the stripe boundaries.

### B. Case of $\phi=0$

When the nematic axis is aligned normal to the surface, we have  $\phi=0$ . In this situation the nonzero components of  $\lambda_{ij}$  read  $\lambda_{11}=\lambda_{22}=1/2$  and  $\lambda_{33}=-1$ , and the normalized surface displacement components are reduced to

$$U_1 = 3[I_1(\rho) - I_3(\rho)],$$

$$U_2 = 0,$$

$$U_3 = -3I_4(\rho). \quad (27)$$

It is interesting that these expressions are attainable directly from Eqs. (26) by taking  $\theta=0$  and then adding a minus sign in front of the result. For any value of the normalized stripe width  $r$ , the corresponding surface topography is a mirror reflection of that described by Eqs. (26) with  $\theta=0$ .

Detailed plots of the surface profiles are not given here. Instead, we provide a brief explanation for the above phenomenon as follows. Imagine that an infinitesimal cuboid with sides parallel to the coordinate axes is isolated from the irradiated part of the elastomer. The light intensity within such a small element is essentially homogeneous. If the nematic axis is along the  $x_1$  direction—i.e.,  $\theta=0$ —a contractible photostrain  $-\varepsilon^*$  is produced in the same direction. Since no deformation in the  $x_2$  direction is allowed, incompressibility of the elastomer leads to an effective expansive strain  $\varepsilon^*$  in the  $x_3$  direction. The reasoning applies equally to the situation if the nematic axis is normal to the surface: a contractible photostrain  $-\varepsilon^*$  in the  $x_3$  direction causes an effective expansion  $\varepsilon^*$  along the  $x_1$  axis. Therefore, the normalized deformations for both alignments of nematic axis are of the same magnitude but opposite signs.

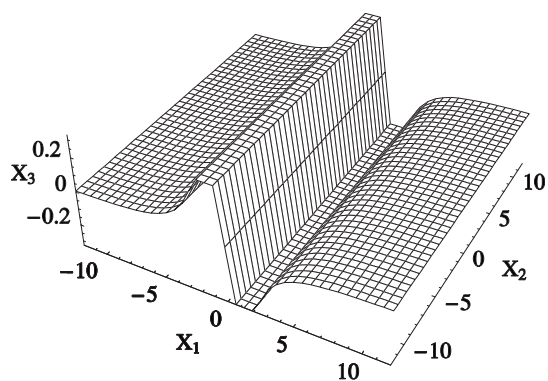
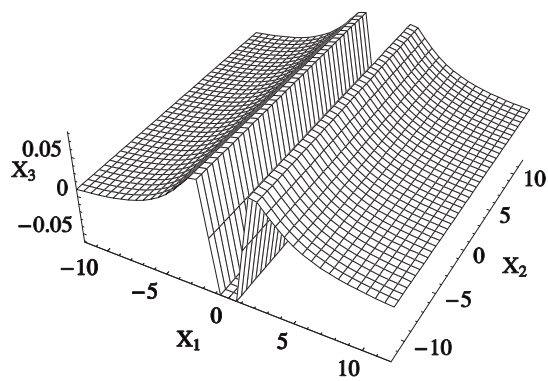
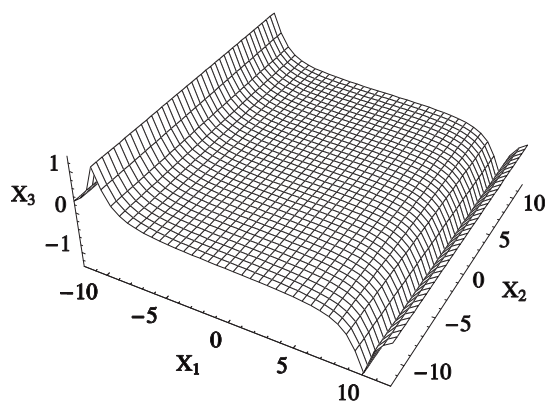
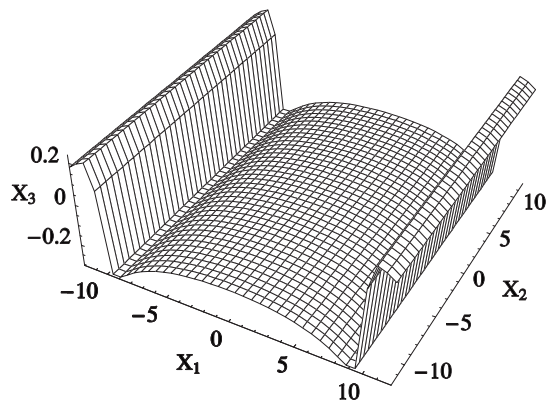
(a)  $r=1$ (a)  $r=1$ (b)  $r=10$ (b)  $r=10$ 

FIG. 9. Surface topographies for two normalized stripe widths: (a)  $r=1$  and (b)  $r=10$ , where the orientation of the nematic axis is given by  $\phi=\pi/4$  and  $\theta=0$ . The scales in the three directions are normalized by  $X_1=x_1/d$ ,  $X_2=x_2/d$ , and  $X_3=\pi x_3/\alpha d l$ , respectively.

### C. Case of $0 < \phi < \pi/2$

In the general situation of  $0 < \phi < \pi/2$ , the nematic axis is neither parallel nor normal to the surface. The surface displacement components are more complicated and are described by the full set of equations (16) and (17). Since  $I_2(\rho)$  and  $I_4(\rho)$  are symmetric while  $I_1(\rho)$  and  $I_3(\rho)$  are antisymmetric about the normalized distance  $\rho$ , we know that each of  $u_1(x_1, 0)$ ,  $u_2(x_1, 0)$ , and  $u_3(x_1, 0)$  is composed of a symmetric and an antisymmetric part. Then, adjusting the three independent parameters  $\phi$ ,  $\theta$ , and  $r$  can lead to diverse surface profiles of the elastomer: symmetric, antisymmetric, and asymmetric. We have examined numerically the influence of the angle  $\phi$  and found that a change in  $\phi$  only leads to quantitative variation of the surface profile. In contrast, the effect of the angle  $\theta$  on the surface topography may be qualitative. Thus, without loss of generality,  $\phi=\pi/4$  is always assumed in the following discussions.

Plotted in Fig. 6 are the variations of  $U_1$  for stripe widths  $r=1, 5$ , and  $10$ . For  $\theta=0$ , the distribution of  $U_1$  is symmetric about the  $x_2$ - $x_3$  plane as its antisymmetric part disappears due to  $\lambda_{11}-\lambda_{33}=0$ . However, this is not the case when  $\phi$  takes values other than  $\pi/4$ . For  $\theta=\pi/4$ ,  $U_1$  distributes asym-

FIG. 10. Surface topographies for two normalized stripe widths: (a)  $r=1$  and (b)  $r=10$ , where the orientation of the nematic axis is given by  $\phi=\pi/4$  and  $\theta=\pi/2$ . The scales in the three directions are normalized by  $X_1=x_1/d$ ,  $X_2=x_2/d$ , and  $X_3=\pi x_3/\alpha d l$ , respectively.

metrically. For  $\theta=\pi/2$ , the symmetric nature of the molecular arrangement in the elastomer dictates  $\lambda_{13}=0$  and hence the antisymmetric distribution of  $U_1$  about  $\rho$ . Demonstrated in Fig. 7 are the variations of  $U_2$  for  $r=1, 5$ , and  $10$ . Because  $U_2=0$  at  $\theta=0$ , the results for  $\theta=\pi/8, \pi/4$ , and  $\pi/2$  are given there. Obviously,  $U_2$  exhibits asymmetric distributions for both  $\theta=\pi/8$  and  $\pi/4$ , but still possesses a symmetric character for  $\theta=\pi/2$  in view of the molecular arrangement that results in  $\lambda_{12}=0$ . The variations of  $U_3$  for  $r=1, 5$ , and  $10$  are depicted in Fig. 8, where  $\theta$  takes the values of  $0, \pi/4$ , and  $\pi/2$ . The distribution of  $U_3$  at  $\theta=0$  is antisymmetric as  $\lambda_{11}-\lambda_{33}=0$ , while symmetric at  $\theta=\pi/2$  due to  $\lambda_{13}=0$ . At the intermediate value of  $\theta=\pi/4$ ,  $U_3$  is neither symmetric nor strictly antisymmetric distributed because  $\lambda_{13}$  and  $\lambda_{11}-\lambda_{33}$  do not vanish in this case.

With the expressions of the displacement components, we can construct the three-dimensional topography of the deformed surface as well. Again, for the reason of  $\alpha l/\pi \ll 1$ , the normalized profile of the surface is nearly the same as that of  $U_3$ . Figures 9(a) and 9(b) show the surface topographies for  $\phi=\pi/4$  and  $\theta=0$  at  $r=1$  and  $10$ , respectively. Each figure combines a ridge and a valley in an antisymmetric pattern, forming a cross section like the letter “N.” Increasing the stripe width  $r$ , the ridge and the valley separate far



away. Figures 10(a) and 10(b) illustrate the surface topographies for  $\phi=\pi/4$  and  $\theta=\pi/2$  at  $r=1$  and 10, respectively. Different from the case of  $\theta=0$ , the surface profiles now become symmetric. For the small stripe width of  $r=1$ , the cross section of the surface profile has the shape of the letter “V,” while for the large stripe width of  $r=10$  the cross section resembles the letter “W.” The scenario is much like that in the case when the nematic axis of the elastomer is aligned normal to the surface—i.e.  $\phi=0$ . The transition of surface topography between the “V” and “W” shapes can be interpreted analogously by elastic confinement from the less deformed underneath material, as elucidated previously for the case of  $\phi=\pi/2$ .

## V. CONCLUSIONS

Surface deformation of azobenzene-containing nematic elastomers induced by a single beam in striped illumination is studied. The orientation of the nematic axis is arbitrary, but the elastic anisotropy of the elastomer is neglected. In addition, only the low-illumination limit is considered, so that the deformation is small. Using a phenomenological continuum model, we obtain an analytical solution to the steady-state surface displacement components. The result enables us to analyze in detail the effect of such factors as the width of the stripe and the orientation of the nematic axis on the surface deformation profile. Indeed, even for the relatively simple

case of a single beam in striped illumination, our work predicts rich surface topographies provided that the orientations of the nematic axis and the stripe width are properly tailored. We thus expect that inhomogeneous illumination can be used as an efficient way to manipulate the surface topography of the nematic elastomers.

In practical applications, one may design diverse illumination patterns by using photomasks so as to produce much more complicated surface features. But sometimes a pattern cannot be simply duplicated onto the elastomer surface because a topographical transition may occur due to elastic confinement when the pattern size is varied, as elucidated in the present analysis. Moreover, at higher light intensity, the relationship between photostrain and intensity is nonlinear [20], and large deformation of the elastomer may lead to elastic buckling in some locations. These issues, along with the effect of elastic anisotropy of the elastomer, remain to be understood thoroughly. Exploration of the problems will be the main content in our future study.

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